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APPLICATION NO. FILING DATE FIRST NAMED INVENTOR ATTORNEY DOCKET NO. CONFIRMATION NO. 10/665,015 09/22/2003 Eigo Shirakashi 60188-649 5843 EXAMINER 7590 09/24/2004 Jack Q. Lever, Jr. MCDONALD, SHANTESE L McDERMOTT, WILL & EMERY ART UNIT PAPER NUMBER 600 Thirteenth Street, N.W. Washington, DC 20005-3096 3723

DATE MAILED: 09/24/2004

Please find below and/or attached an Office communication concerning this application or proceeding.

		A
	Application No.	Applicant(s)
	10/665,015	SHIRAKASHI ET AL.
Office Action Summary	Examiner	Art Unit
	Shantese L. McDonald	3723
The MAILING DATE of this communication a Period for Reply	appears on the cover sheet with	the correspondence address
A SHORTENED STATUTORY PERIOD FOR REF THE MAILING DATE OF THIS COMMUNICATION - Extensions of time may be available under the provisions of 37 CFR after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a r - If NO period for reply is specified above, the maximum statutory perion - Failure to reply within the set or extended period for reply will, by stat Any reply received by the Office later than three months after the ma earned patent term adjustment. See 37 CFR 1.704(b).	N. 1.136(a). In no event, however, may a reply reply within the statutory minimum of thirty (3 od will apply and will expire SIX (6) MONTH tute, cause the application to become ABAN	be timely filed io) days will be considered timely. S from the mailing date of this communication. DONED (35 U.S.C. § 133).
Status		
1) Responsive to communication(s) filed on 22	September 2003.	
2a) This action is FINAL . 2b) ⊠ The	his action is non-final.	
3) Since this application is in condition for allow	vance except for formal matters	s, prosecution as to the merits is
closed in accordance with the practice unde	r <i>Ex parte Quayle</i> , 1935 C.D. 1	1, 453 O.G. 213.
Disposition of Claims		
4) Claim(s) 1-9 is/are pending in the application 4a) Of the above claim(s) is/are withden 5) Claim(s) is/are allowed. 6) Claim(s) 1-9 is/are rejected. 7) Claim(s) is/are objected to. 8) Claim(s) are subject to restriction and	rawn from consideration.	
Application Papers		
9)☐ The specification is objected to by the Exami	iner.	
10)☐ The drawing(s) filed on is/are: a)☐ a		
Applicant may not request that any objection to the	, , ,	• •
Replacement drawing sheet(s) including the correct 11) The oath or declaration is objected to by the		• • • • • • • • • • • • • • • • • • • •
	Examiner. Note the attached C	mod Action of Torm 1 TO 132.
Priority under 35 U.S.C. § 119		
 12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority docume 2. Certified copies of the priority docume 3. Copies of the certified copies of the priority docume application from the International Bure 	ents have been received. ents have been received in Applicionity documents have been received.	lication No
* See the attached detailed Office action for a li	•	eived.
Attachment(s)	🗖	
 Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-948) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/0 Paper No(s)/Mail Date <u>9/22/03</u>. 		mary (PTO-413) lail Date mal Patent Application (PTO-152)

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DETAILED ACTION

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claims 1-9 are rejected under 35 U.S.C. 102(b) as being anticipated by Cheng et al.

Cheng et al teaches a method for polishing a wafer which is polished by continuously driving a surface late, 101, on which a plurality of polishing pads, 201, made of polyurethane foam, (col. 4, lines 38-39), are stuck, the surface of each pads being provided with a plurality of grooves each extending in the drive direction of the pad, wherein in the sticking step, the polishing pads are stuck on the surface of the plate, (col.5, lines 49-60), in such a manner that the grooves of each of the polishing pads are spaced not to align with the respective grooves of the polishing pad adjacently arranged in the drive direction and therefore are offset by a predetermined distance form the grooves of the polishing pad adjacently arranged, (fig. 5. if the mosaic pads are placed adjacent to each other, the grooves will not align). Cheng et al. also teaches a plurality of grooves extending in the drive direction of the polishing pad which are formed over the entire width, at regular intervals, from edge to edge of the polishing pad in the direction perpendicular to the drive direction, (figs. 4a and 4b), and the grooves extending in the drive direction at an angle relative to the drive direction at regular intervals, (fig. 3b).

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Conclusion

The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Naujok was cited to show another example of a polishing pad.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Shantese L. McDonald whose telephone number is (703) 308-8722. The examiner can normally be reached on 8:00 a.m. - 4:30 p.m..

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Joseph Hail can be reached on (703) 308-2687. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

S.L.M. September 16, 2004

Joseph J. Hail, III Supervisory Patent Examiner Technology Center 3700

Joseph J. Harlas